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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 1092**
Hiroto YUKAWA et al. : Docket No. 2004_0499
Serial No. 10/810,902 : Group Art Unit 1752
Filed March 29, 2004 : Examiner Sin J. Lee

POSITIVE-WORKING CHEMICAL-
AMPLIFICATION PHOTORESIST
COMPOSITION

Mail Stop: AMENDMENT

RESPONSE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated October 1, 2004, please amend the present application as follows: